

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFIC

In re the Application of

Akira SHIMOKOHBE et al.

Application No.: 09/556,795

Filed: April 25, 2000

Group Art Unit: 2813

Examiner:

Asok K. Sarkar

Docket No.:

106096

A THIN FILM-STRUCTURE AND A METHOD FOR PRODUCING THE SAME

AMENDMENT UNDER 37 C.F.R. §1.111

Director of the U.S. Patent and Trademark Office Washington, D.C. 20231

Sir:

For:

In reply to the Office Action mailed March 1, 2001, please amend the above-identified application as follows:

IN THE ABSTRACT:

Please replace the Abstract with the attached Abstract hereto.

IN THE SPECIFICATION:

Page 3, between lines 3 and 6, insert a new paragraph as follows:

This invention addresses the above-mentioned problems by developing a new material constituting the thin-film structure and a method for producing them as follows:

Page 9, between lines 9 and 12, insert a new paragraph as follows:

In using an appropriate micro pin-driving machine such as a micro manipulator, the thin film may be directly deformed during the heat-holding through the micro pin attached to the machine after it is heated to the temperature of the supercooled liquid phase region.

